



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Re the Application of: **Miwa KOZAWA et al.**

Art Unit: 1795

Application Number: **10/720,097**

Examiner: **Daborah Chacko Davis**

Filed: **November 25, 2003**

Confirmation Number: **4454**

For: **PROCESS FOR FORMING RESIST PATTERN, SEMICONDUCTOR DEVICE  
AND FABRICATION THEREOF**

Attorney Docket Number: **032132**

Customer Number: **38834**

**PETITION FOR EXTENSION OF TIME**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

February 9, 2009

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated October 7, 2008 for one month from January 7, 2009 to February 7, 2009.

Attached please find payment in the amount of \$130.00 for the cost of the extension of time. If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

**WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP**

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